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(54) Title: METHOD OF PRODUCING A POROUS PLASTIC FILM, AND PLASTIC FILM



(57) Abstract: A method of producing a porous plastic film, and a porous plastic film. The plastic film is prepared from a raw material blend comprising a polymer-containing basic material and an additive. Pores are generated in the film by stretching a film preform. The additive comprises a POS(S) chemical.

WO 2005/044902 A1



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